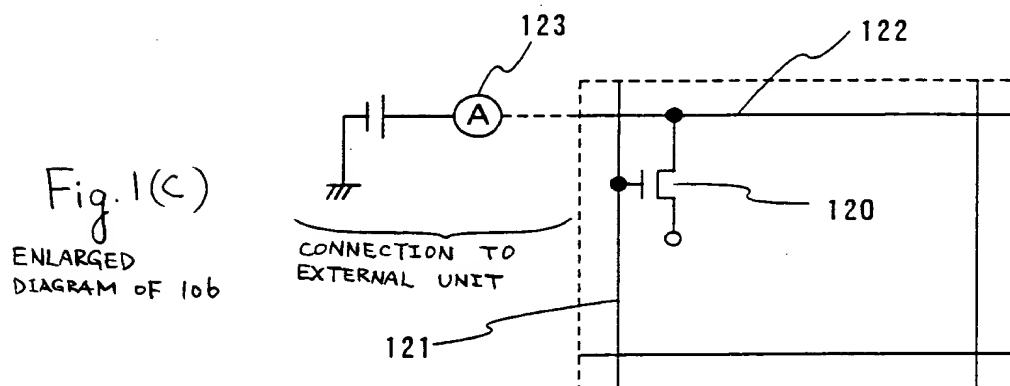
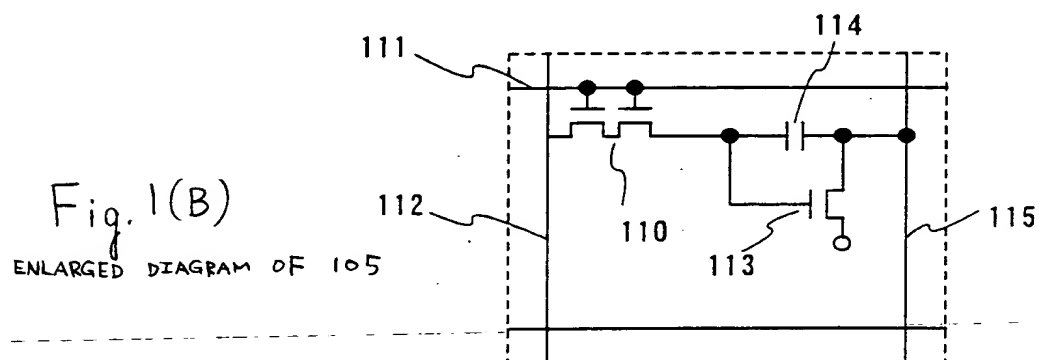
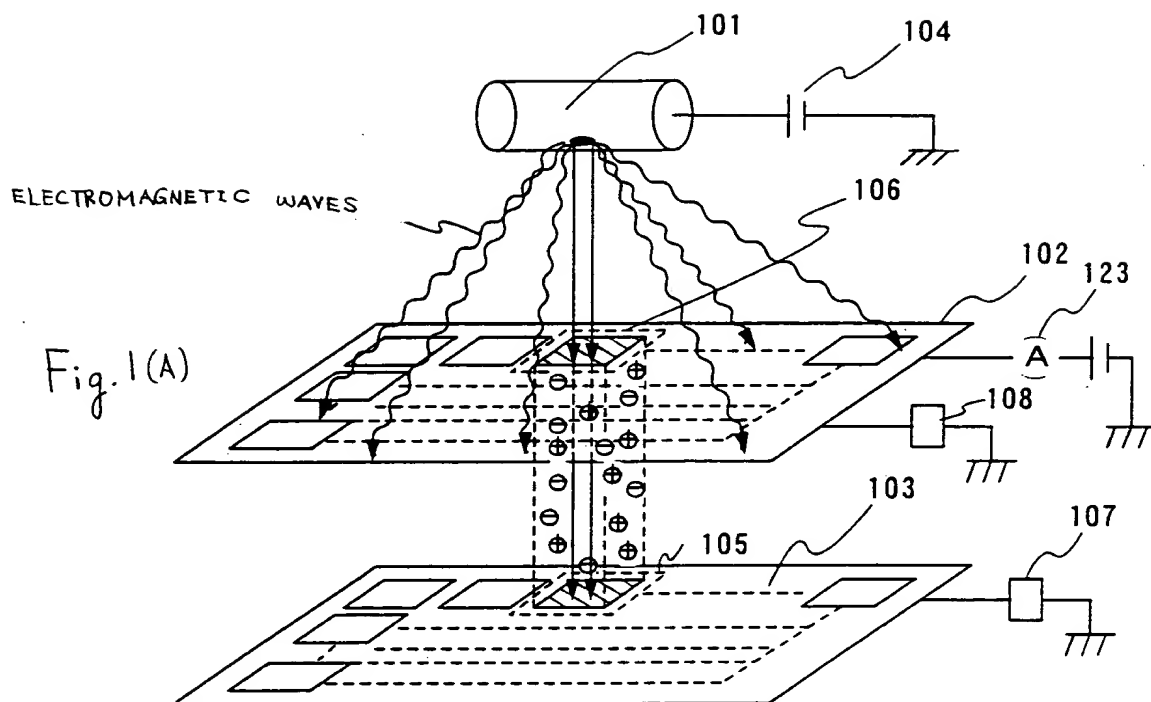


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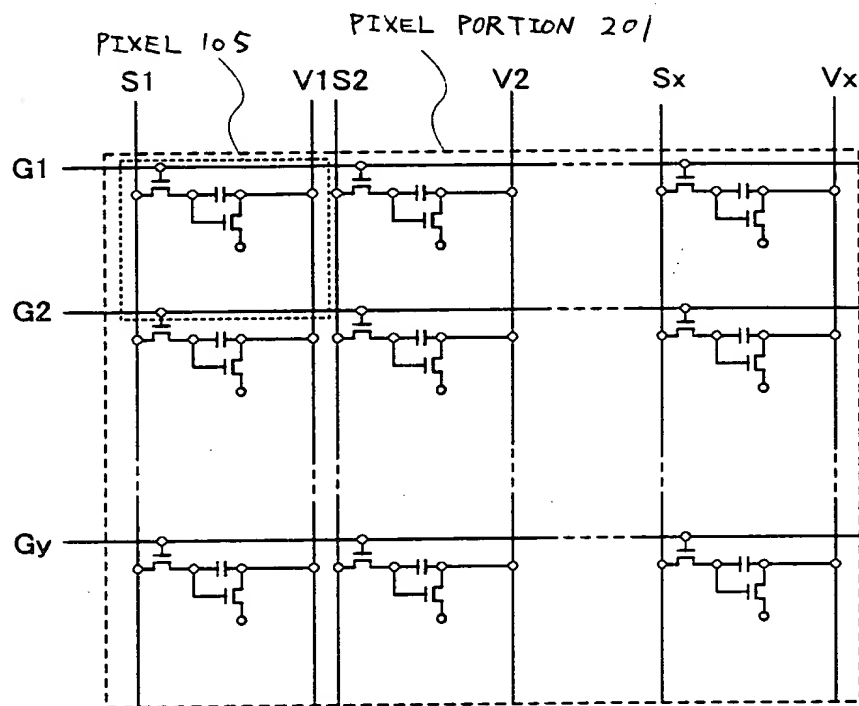


Fig. 2(A)

OPPOSING PORTION 106

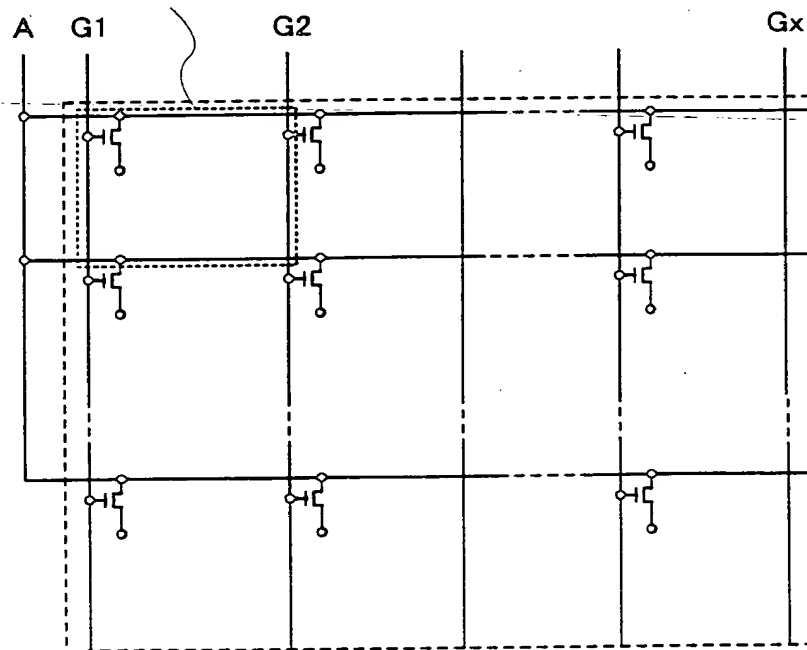


Fig. 2(B)

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 100E50" 15999860

Fig. 3(A)

(1, 1)	(2, 1)	(3, 1)	(4, 1)		(x-1, 1)	(x, 1)
(1, 2)	(2, 2)	(3, 2)	(4, 2)		(x-1, 2)	(x, 2)
(1, 3)	(2, 3)	(3, 3)	(4, 3)		(x-1, 3)	(x, 3)
(1, 4)	(2, 4)	(3, 4)	(4, 4)		(x-1, 4)	(x, 4)
(1, y-1)	(2, y-1)	(3, y-1)	(4, y-1)		(x-1, y-1)	(x, y-1)
(1, y)	(2, y)	(3, y)	(4, y)		(x-1, y)	(x, y)

Fig. 3(B)

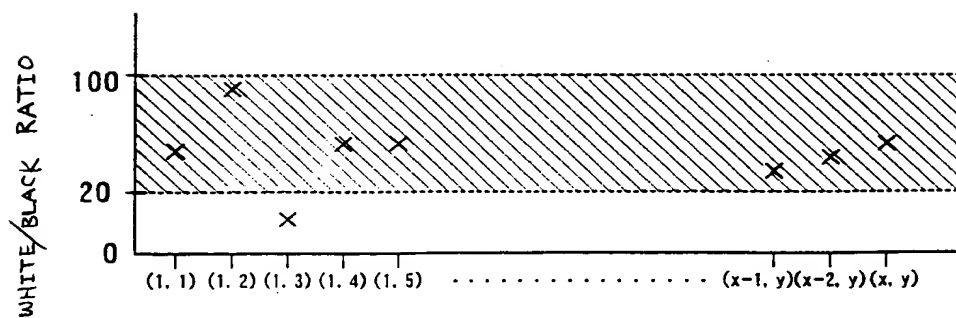




Fig. 5(A) SECOND DOPING

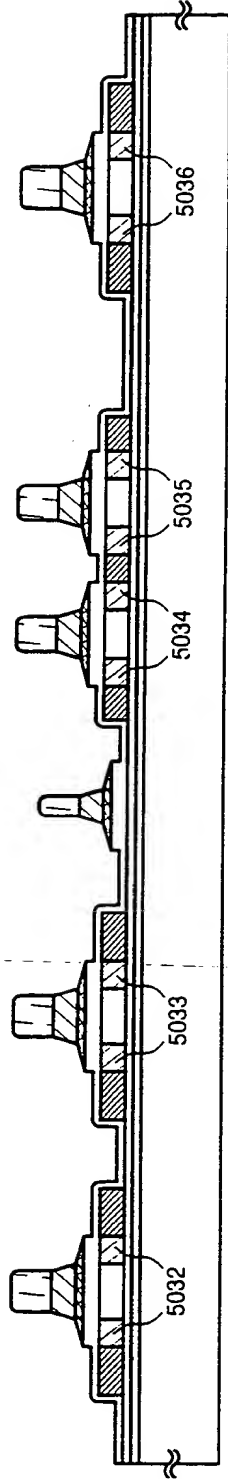


Fig. 5(B) THIRD ETCHING

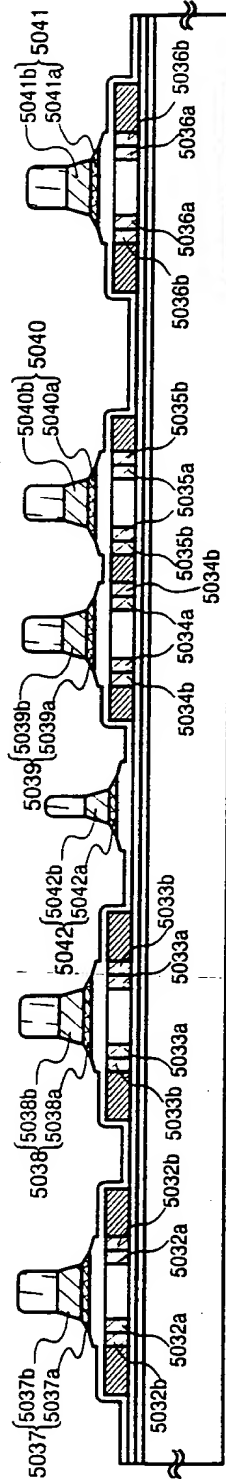
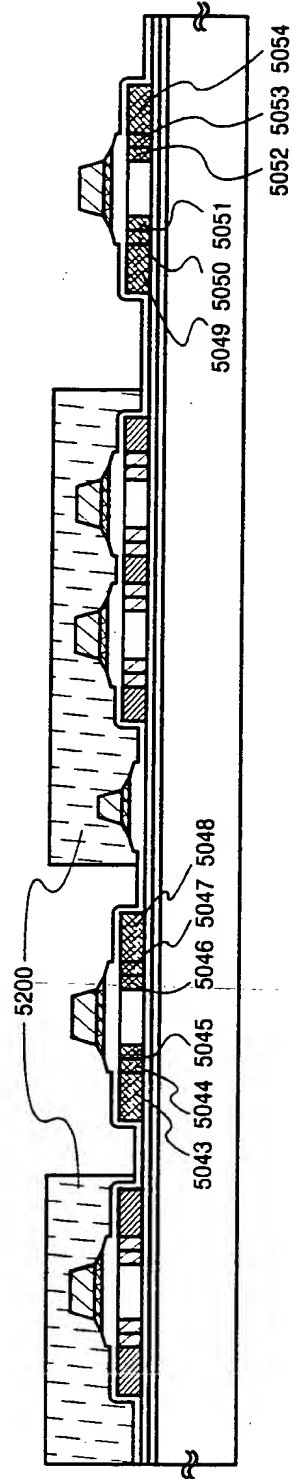
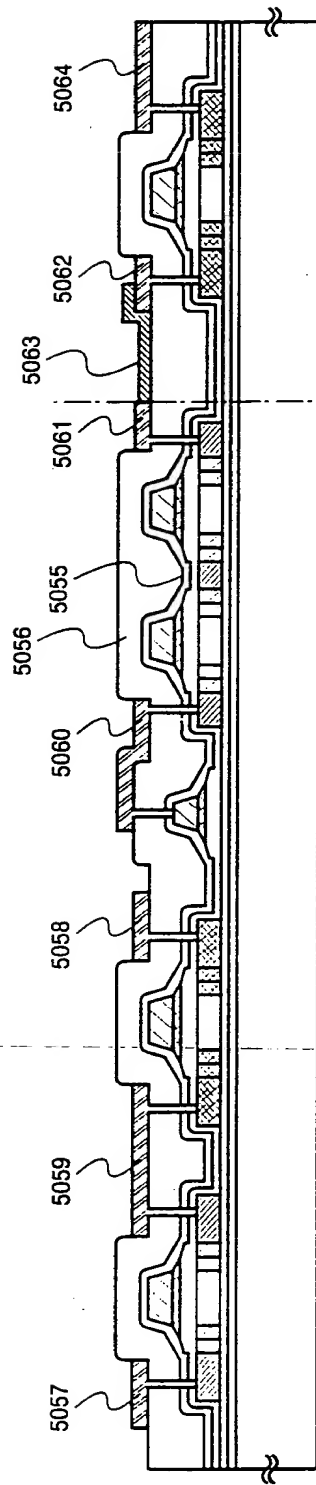


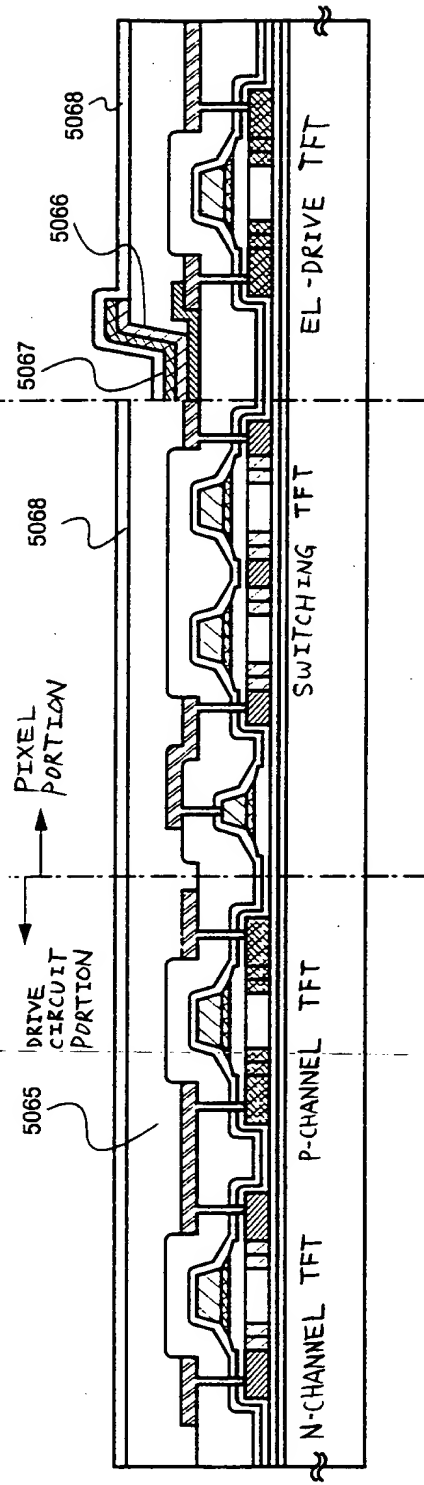
Fig. 5(c) THIRD DOPING

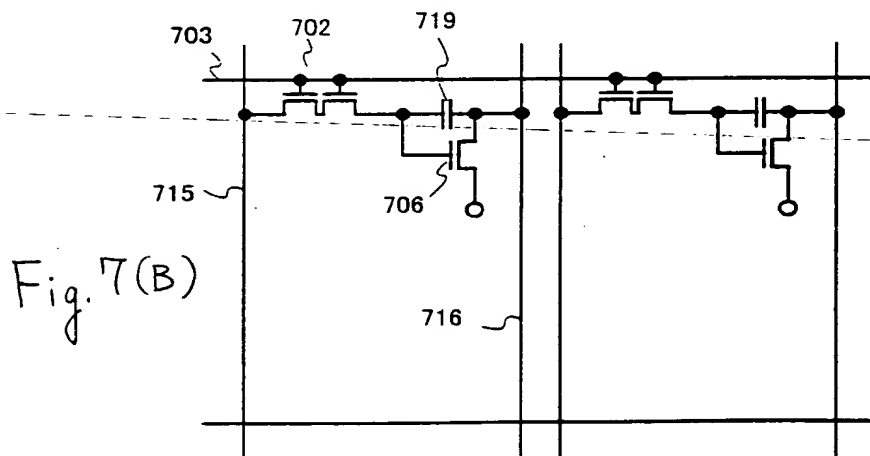
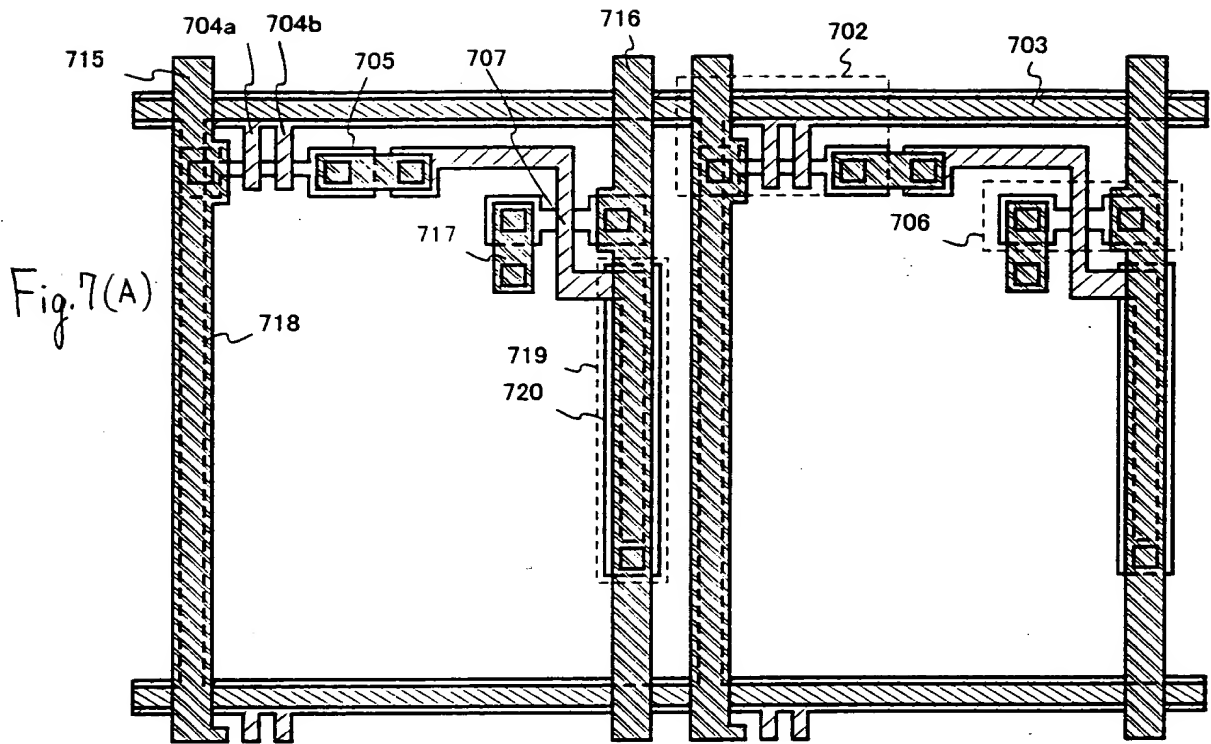


FORMATION OF THE FIRST AND SECOND INTERLAYER-INSULATING FILMS,  
Fig. 6(A) WIRINGS AND PIXEL ELECTRODES

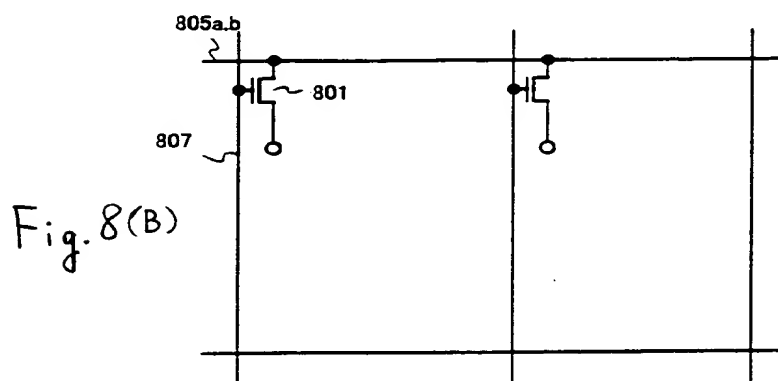
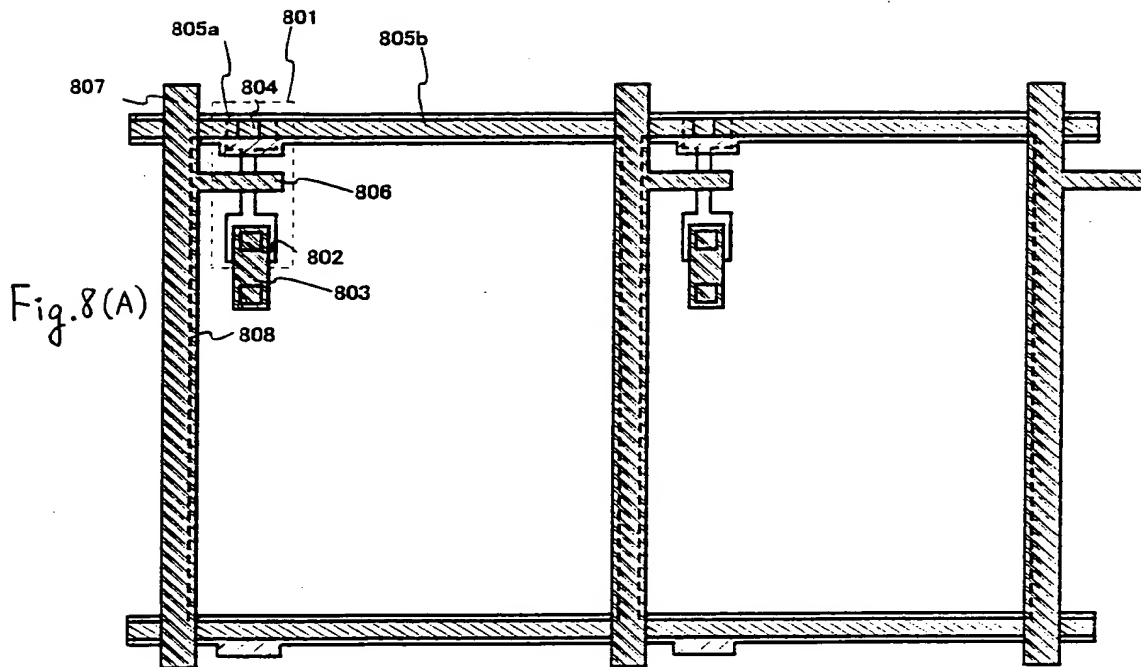


FORMATION OF THE THIRD INTERLAYER-INSULATING FILM, EL LAYER,  
Fig. 6(B) CATHODES AND PASSIVATION FILM





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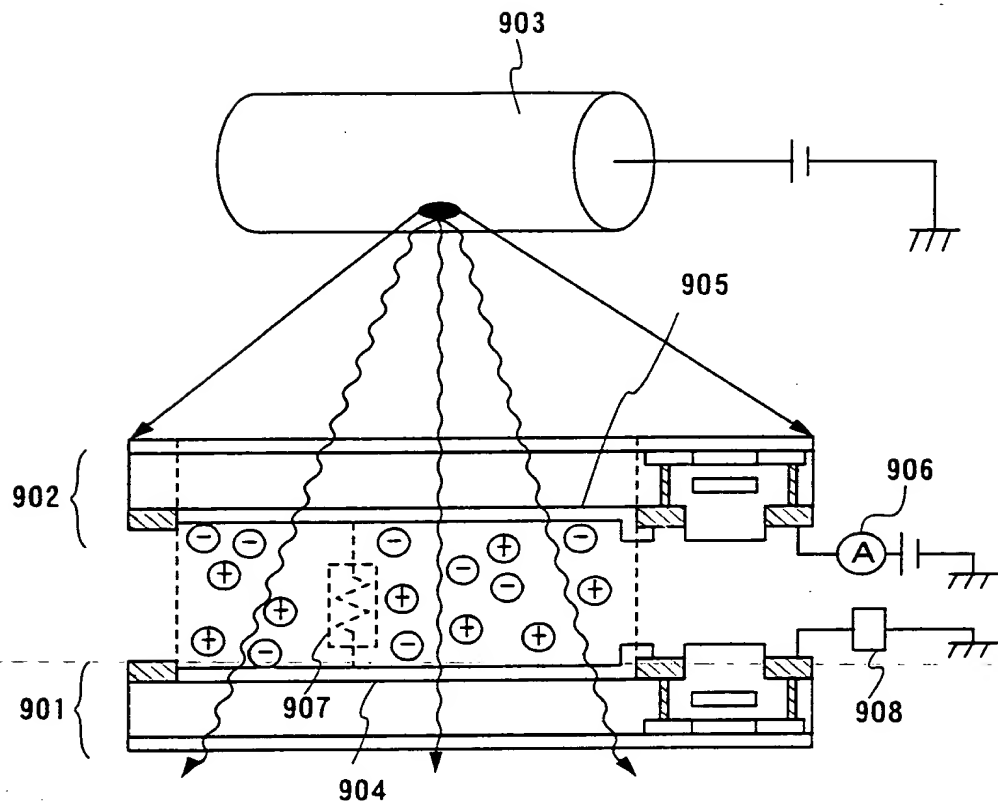


Fig. 9

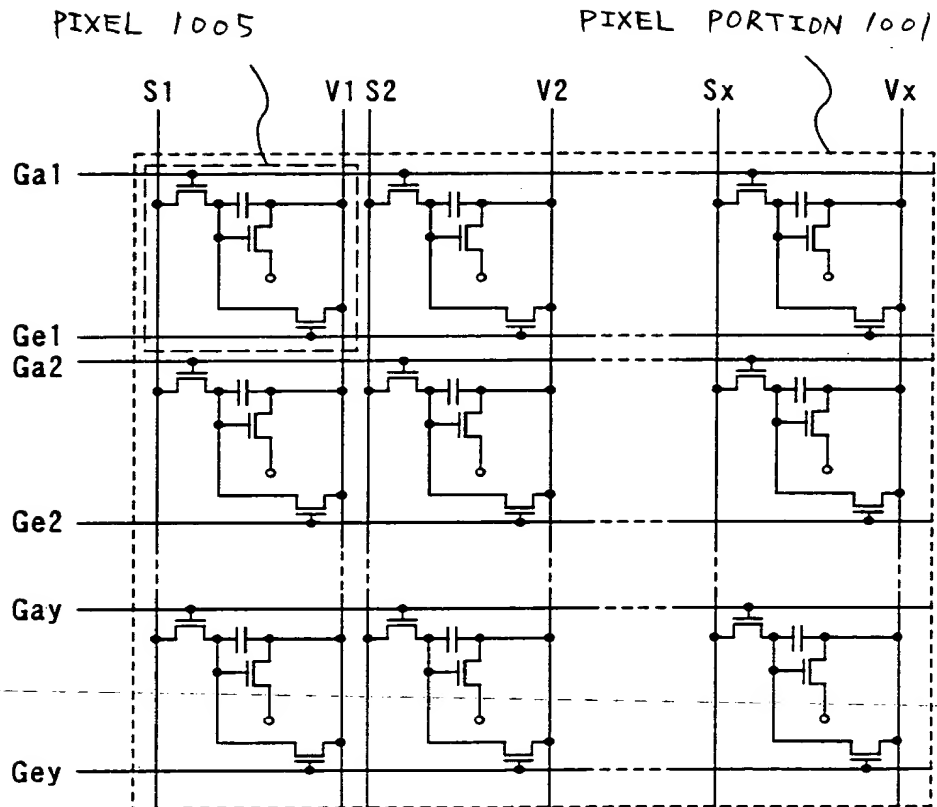


Fig. 10

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SOURCE OF ELECTROMAGNETIC  
WAVES 1101

POWER SOURCE 1104

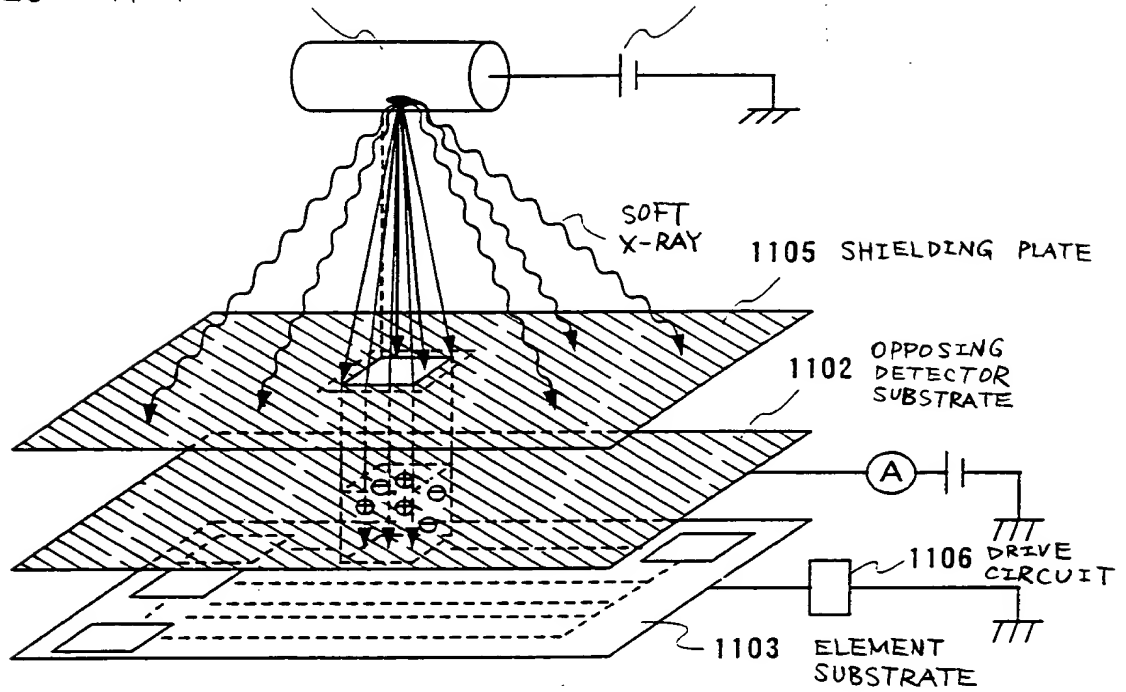


Fig. 11

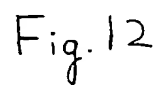


Fig. 13(A)

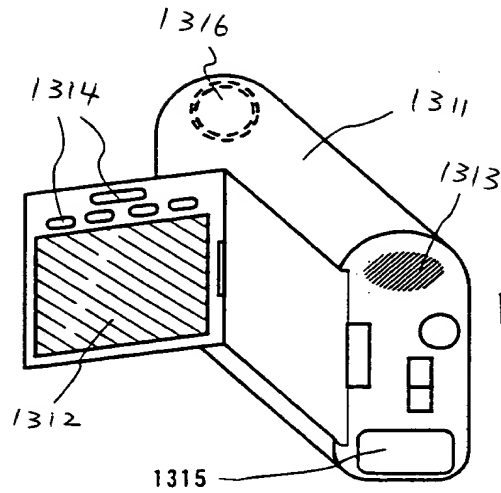
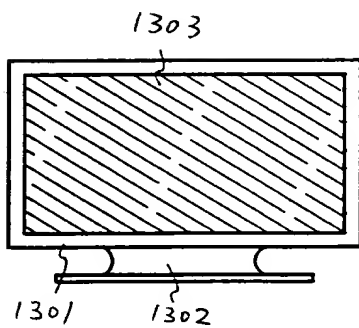


Fig. 13(B)

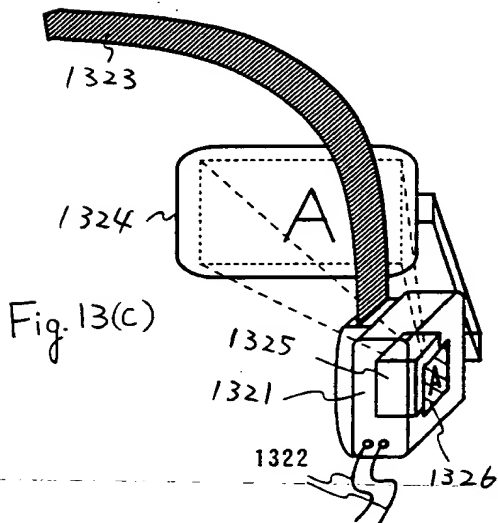


Fig. 13(C)

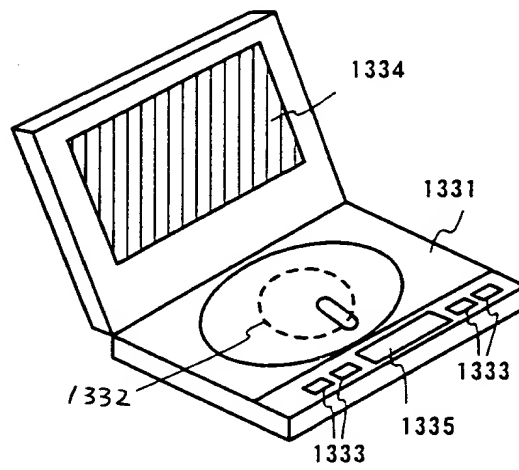


Fig. 13(D)

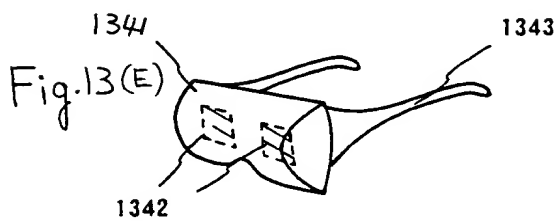


Fig. 13(E)

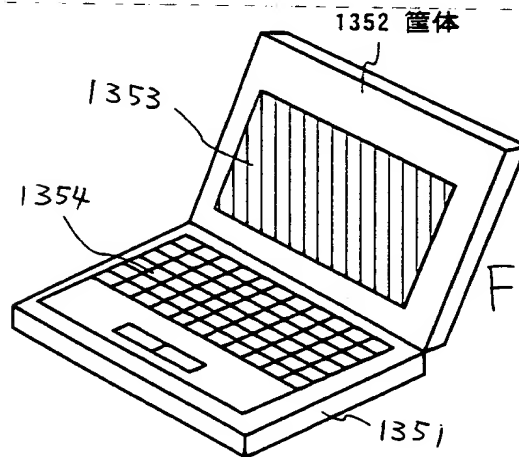


Fig. 13(F)

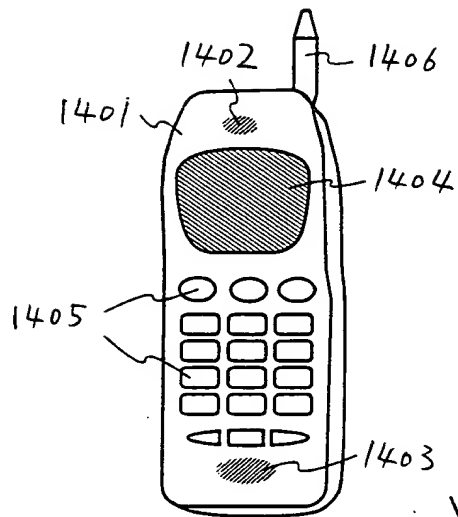


Fig. 14(A)

Fig. 14(B)

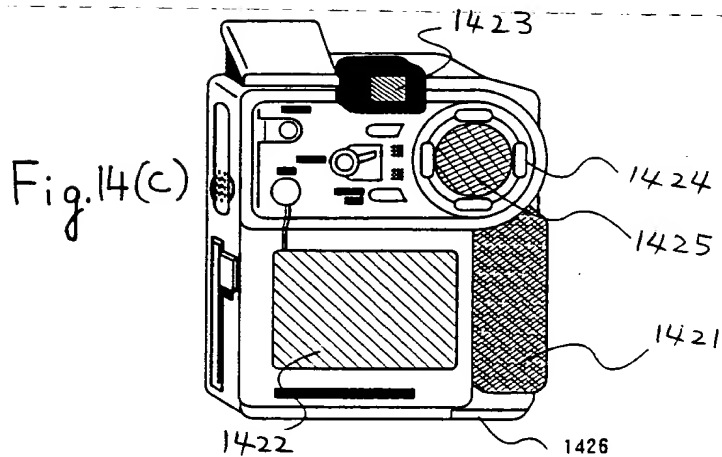
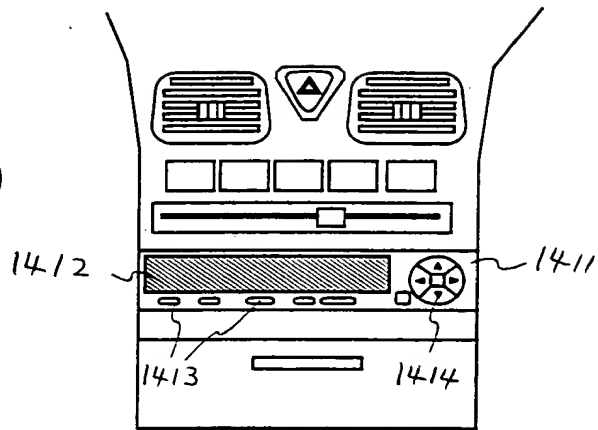


Fig. 15

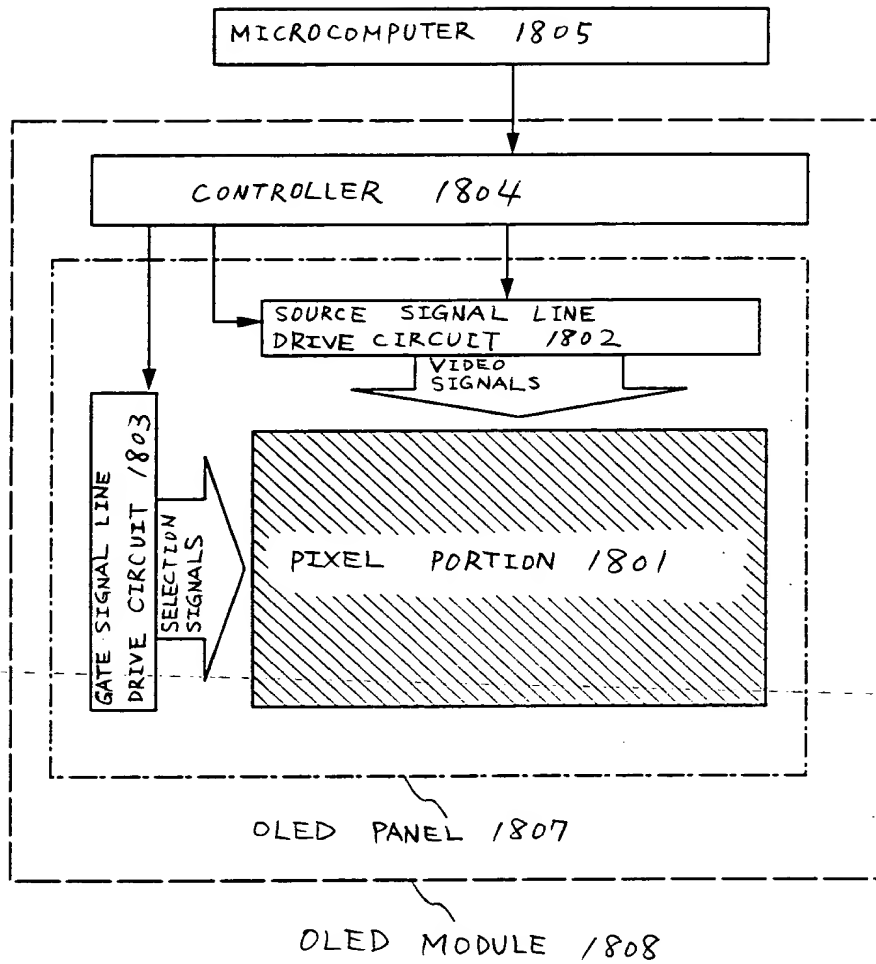


FIG. 15

Fig. 16(A)

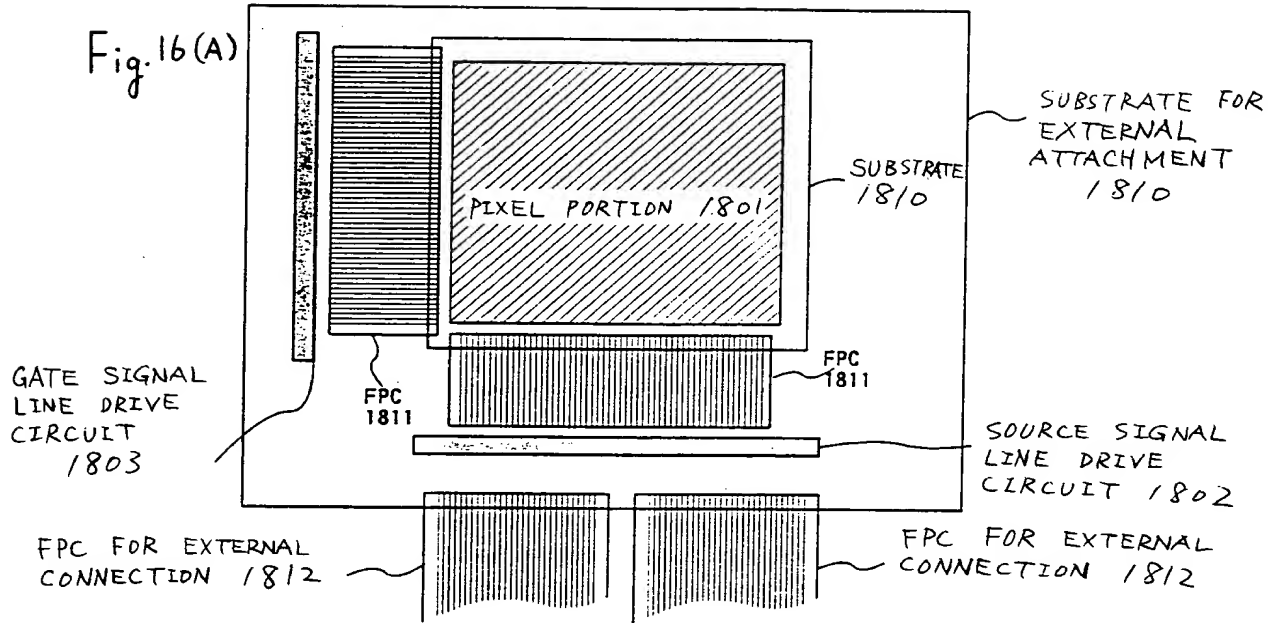


Fig. 16(B)

